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CoPt hard magnetic nanoparticle films synthesized by high temperature chemical reduction

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The synthesis of hard-magnetic CoPt nanoparticle films by hydrogen reduction of Co nitride and Pt chloride mixture is reported. Thin porous alumina films are adopted as the carrier of the initial aqueous solution and of the final reducing products of CoPt nanoparticles. It is found that chemical ordering of $L1_0$ -CoPt occurs above 400 °C. Partial phase transformation occurs in the alumina substrate when the treatment temperature is higher than 600 °C. The film coercivity increases with increasing annealing temperature and reaches a maximum value of 24.2 kOe when the reduction is carried out at 700 °C for 2 h. © 2003 American Institute of Physics. [DOI: 10.1063/1.1544501]

I. INTRODUCTION

The high magnetic anisotropy of FePt and CoPt with ordered $L1_0$ structure, $K_1=6.6$ and 4.9 MJ m^{-3} , respectively, makes nanoparticulate films of these compounds promising candidates for high-density magnetic recording media and high-energy-product nanocomposite permanent magnets.¹⁻⁴ Recently, Sun *et al.* have prepared FePt nanoparticles by simultaneous reduction of platinum acetylacetonate and thermal decomposition of iron pentacarbonyl.¹ Upon annealing at 550 °C, the nanoparticles with face-centered-cubic structure transformed to face-centered-tetragonal particles whose coercivity depends on the annealing temperature. The highest coercivity value was about 20 kOe, which was obtained by annealing at 600 °C for 1 h. Strongly exchange-coupled FePt nanoparticle assemblies also were obtained.³ As an alternative method of material synthesis, we introduce a hydrogen-reduction method for CoPt $L1_0$ nanoparticle film preparation. The magnetic properties of CoPt $L1_0$ nanoparticle films are discussed together with the hydrogen reduction and CoPt $L1_0$ phase-formation processes.

II. EXPERIMENTAL METHOD

Porous alumina films (PAF) were prepared first and used as substrate for the growth of CoPt nanoparticles. Electrochemically polished aluminum plates were anodized in a 0.3 M oxalic acid aqueous solution at 60 V for 2 min. Then they were soaked in 5% phosphorous acid solution for 30 min for pore widening. The preparation details can be found elsewhere.⁵ By this method, PAFs with a thickness of about 1.8 μm and a pore diameter of about 100 nm were obtained. Second, 1 M aqueous solutions of $\text{Co}(\text{NO}_3)_2 \cdot 9\text{H}_2\text{O}$, $\text{H}_2\text{PtCl}_6 \cdot 6\text{H}_2\text{O}$, and 1:1 molar ratio of their mixture were

prepared separately, and were loaded onto the PAFs by spin coating. The loaded films were dried in vacuum for 2 h, then transported into a tubular furnace, and finally treated in flowing hydrogen for specified times and temperatures.

Structural characterization was carried out using x-ray diffractometry (XRD) with Cu $K\alpha$ radiation. Magnetic properties were measured using a Quantum Design superconducting quantum interference device. Magnetic force microscopy (MFM) images and the topography of the films were obtained using a MFM with low magnetic stray field and high-coercivity MFM tips.

III. RESULTS AND DISCUSSION

A. Thermal stability of porous alumina, Co nitride, and Pt chloride

As all hydrogen reductions were carried out in the PAF, it was important to understand the thermal stability of PAF,

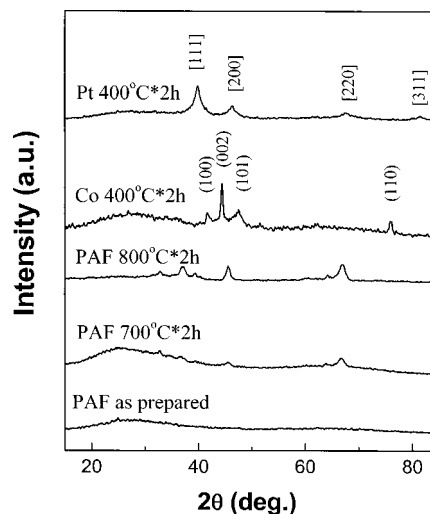


FIG. 1. XRD patterns of as prepared PAF and those treated in hydrogen at 700 and 800 °C, respectively. Pure Co and Pt on PAF by hydrogen reduction at 400 °C for 2 h.

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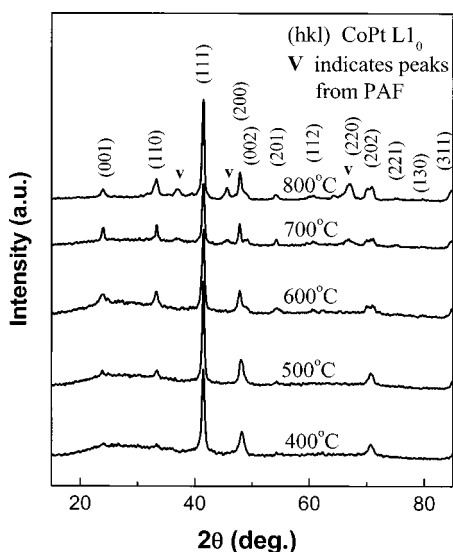


FIG. 2. XRD patterns of CoPt alloys on PAF obtained by hydrogen reduction at different temperature for 2 h. V indicates the main peaks from alumina matrix due to partial crystallization of PAF.

Co nitride, and Pt chloride salts—particularly with respect to the reducing process, phase formation, etc. XRD patterns of as-prepared PAF and those treated at 700 and 800 °C for 2 h in flowing hydrogen are shown in Fig. 1. In order to know the thermal stability of Co and Pt salt, two additional samples were made. One PAF was loaded with 1 M aqueous solution of Co nitride, the other one was loaded with Pt chloride solution. Both of them were treated in hydrogen at 400 °C for 2 h. The corresponding XRD patterns are also shown in Fig. 1.

It is generally recognized that the PAF is amorphous or nanocrystalline with a mean crystallite size of less than 4 nm.⁶ Our results show that the PAF remained amorphous when the treating temperature is equal to or lower than 600 °C for 2 h. When the treating temperature is as high as 700 °C, partial crystallization is observed.

Although the treating temperature is only 400 °C, both pure Pt (fcc) and Co (hexagonal) are produced from their salt, as can be seen from Fig. 1. This means that both Co and Pt salt can be reduced by hydrogen at 400 °C. It also indicates that hydrogen is not only a clean and cheap reducing agent, but also an efficient one. The likely reactions are $\text{Co}(\text{NO}_3)_2 \cdot 9\text{H}_2\text{O} + \text{H}_2 \rightarrow \text{Co} + \text{H}_2\text{O} + \text{NO}_2$ and $\text{H}_2\text{PtCl}_6 \cdot 6\text{H}_2\text{O} + \text{H}_2 \rightarrow \text{Pt} + \text{H}_2\text{O} + \text{HCl}$.

B. Reduction of Co and Pt salt mixture and ordering of L1₀-CoPt

When the PAFs are loaded with 1 M aqueous solution of Co and Pt salt mixture, and reduced at specified temperature for 2 h, the CoPt alloy is obtained. The XRD patterns are shown in Fig. 2. When 1 M Co nitride solution alone was reduced on a PAF at 400 °C for 2 h, the film consists of pure Co nanoparticles with coercivity value of 500 Oe. When 1 M Co and Pt salt mixture was reduced on a PAF, coercivity of 2.0 kOe was reached after the same treatment. Considering the XRD patterns, it is concluded that the ordering process starts at 400 °C. It was reported that, with Ag addition, the

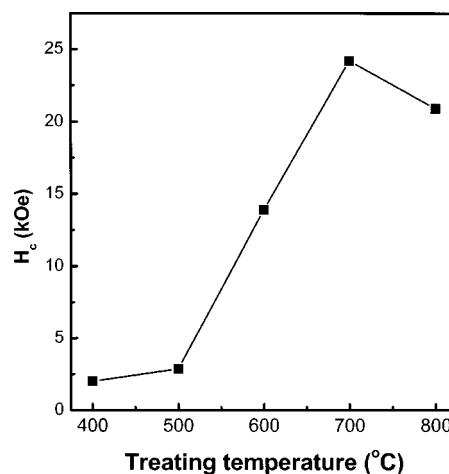


FIG. 3. Coercivities of CoPt hard magnetic films vs treating temperatures. All the samples were treated for 2 h in flowing hydrogen.

formation temperature of the CoPt L1₀ phase in CoPt/SiO₂ multilayers starts at 550 °C.⁷ By adding Sn, Pb, Sb, and Bi, the ordering temperature of L1₀ CoPt decreased to 400 °C.⁸ For Co/Pt multilayers, it was estimated that the activation energy for the ordering is 2.1 eV, which is lower than the self-diffusion energy of Pt and β-Co. The possible reasons for this lower energy are gradient diffusion and the large chemical diffusivity of Co in Pt.⁹ In our case, the Co and Pt atoms are released one-by-one during reduction, but the releasing does not occur simultaneously for Pt and Co. Pt is reduced first, followed by Co. The newly released Co atom may have higher chemical activity, which make its diffusion easier to neighboring Pt particles, so the ordering starts from a lower temperature.

Figure 3 shows the coercivities of the films versus treating temperatures. All samples were treated in flowing hydrogen for 2 h. Although CoPt L1₀ phase ordering began at 400 °C, the coercivity is lower when the treating temperature

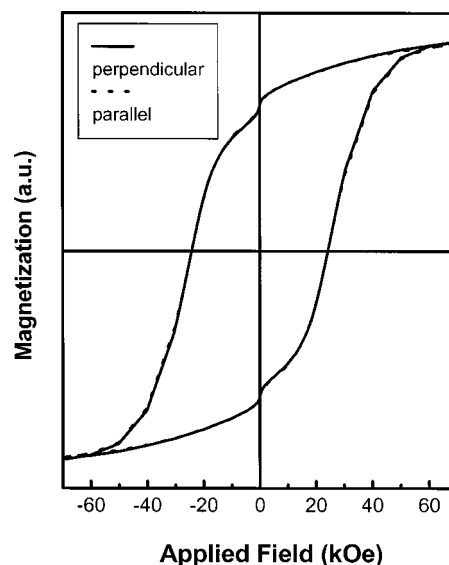


FIG. 4. Two hysteresis loops of a sample treated at 700 °C for 2 h and measured with the external field perpendicular and parallel to the film. The coercivity is 24.2 kOe.

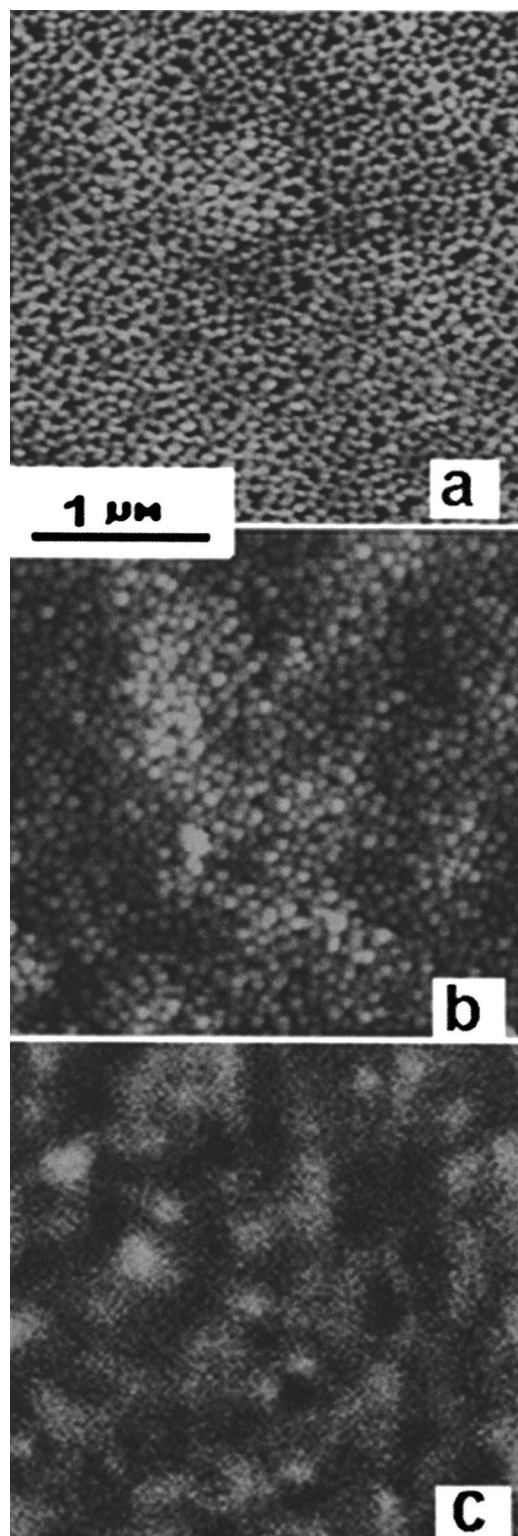


FIG. 5. AFM topographies: (a) as prepared PAF, (b) loaded PAF treated at 700 °C for 2 h, and (c) MFM image on the same region (b).

is less than 500 °C. Higher coercivity is reached only when the treating temperature is higher than 600 °C. The coercivity of CoPt nanoparticles with $L1_0$ structure originates from its magnetocrystalline anisotropy K_u , which is associated with the degree of its chemical order. It depends strongly on the treating temperature, because high temperature treatment is necessary to optimize the chemical ordering and to realize

a high coercivity. When the treating temperature is 600 °C or higher, the coercivity increases drastically, reaching a maximum value of 24.2 kOe at 700 °C. Further increase of treating temperature decreases the coercivity. Figure 4 shows two hysteresis loops of a sample reduced at 700 °C for 2 h, measured with external field perpendicular and parallel to the film. No anisotropic behavior was observed, which holds true for other samples treated at different temperatures.

The average CoPt particle sizes were extracted from the x-ray patterns using the Scherrer formula. As the treating temperature increase, the average size of the CoPt particles increases from 18 nm (treated at 600 °C) to 32 nm (treated at 800 °C). When the film is treated at 600 °C for 2 h, the remanence ratio is 0.72, as compared to the remanence ratio of 0.5 for randomly oriented, noninteracting Stoner–Wohlfarth particles. This higher remanence ratio suggests that the CoPt nanoparticles form agglomerates so that exchange coupling between them increases the remanence ratio.

C. Film topography and MFM images

Figures 5(a) and 5(b) are topographies of as prepared PAF and a CoPt hard magnetic film (treated at 700 °C for 2 h), respectively. Figure 5(c) is a MFM image on the same area as Fig. 5(b). Closely packed pores with diameter around 100 nm were observed by AFM examination in as prepared PAF. After solution loading and hydrogen reduction, the pore openings are partially covered by the CoPt particles. The MFM images show that the film has maze-like domain structure, which indicates that particles are coupled together to form domains with sizes of order 300 nm.

IV. CONCLUSION

CoPt hard magnetic films were produced by loading aqueous solution of CoPt mixture salt into PAF and employing hydrogen reduction at elevated temperature. The highest coercivity value is 24.2 kOe. The ordering of $L1_0$ CoPt starts from 400 °C. The partial crystallization of alumina matrix does not affect the chemical ordering and the magnetic properties of the CoPt particles. The AFM images reveal that the pores of PAF substrate are partially covered with CoPt particles. The hard magnetic film has a maze-like domain structure.

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